<u>Quick Reference Guide for Thermal Design</u> <u>for Power Semiconductor SMD type</u>

SMD : Surface Mount Device

Outline:

This application note is a supplement to other documents about thermal design. The information contained herein is more concise and easier to understand and shows only thermal tendencies using simplified models.

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0. Introduction: Quick Reference Guide for Thermal Design for Power Semiconductor SMD type

0.1. Background

Power Semiconductor SMD type in automotive and high-power electronic applications are becoming exposed to increasingly high temperature because of 1) a reduction in system size, 2) an increase in board assembly density, and 3) an increase in system power consumption due to performance enhancement. It is therefore important to grasp the thermal profile of your system design in the early stages of development. Under these circumstances, Toshiba provides several application notes on its website to help you reduce chip temperature and thereby facilitate thermal design. Lately, Toshiba released *Hints and Tips for Thermal Design for Discrete Semiconductor Devices — Part 2* that provides the results of simulations using natural convection models and *Hints and Tips for Thermal Design for Discrete Semiconductor Devices — Part 3* that summarizes the results of simulations using forced-convection models that emulate real hardware conditions more closely. Since these application notes were published, we have received feedback from their readers, saying that they need a handy at-a-glance guide to know just enough about thermal design quickly.

The Quick Reference Guide for Thermal Design for Power Semiconductor SMD type provides at-a-glance information as a supplement to other application notes. It shows only thermal tendencies using simplified models. The device and board models used herein are identical to the simplified models used in the previous application notes. The board model used as a baseline represents a 1.6-mm-thick four-layer board with a trace thickness of 35 µm. The Quick Reference Guide for Thermal Design for Discrete Semiconductor Devices is formatted as questions and answers, using as a reference the results of analyses contained in *Hints and Tips for Thermal Design for Discrete Semiconductor Devices*, Part 2 and Part 3.

We hope this quick reference guide will be your useful companion for understanding thermal behavior.

0.2. Summary

The following table summarizes the simulation results. You can confirm the tendencies in thermal resistance that were revealed by simulation in the following table.

| Contents | Countermeasure | Reduction in thermal resistance |
|--|--|--|
| 1. Board size vs. thermal resistance | Increasing the board size | Four-layer board one inch square ⇒ four-layer board two inches square: 47% reduction (Effective for boards up to two inches square) |
| 2. Number of board layers vs. thermal resistance | Increasing the number of board layers | 4 layers \Rightarrow 8 layers: 14% reduction |
| 3. Trace thickness on outer board layers vs. thermal resistance | Increasing the thickness of traces on outer layers | 35 µm ⇒ 105 µm: 13% reduction |
| 4. Board Cu coverage vs. thermal resistance #1 | Increasing Cu coverage | 20% \Rightarrow 100%: 45% reduction |
| 5. Board Cu coverage vs. thermal resistance #2 | Increasing the width of board traces near heat sources | Narrow traces \Rightarrow Wide traces : 4% reduction |
| 6. Number of vias just below E-pad vs. thermal resistance | Increasing the number of thermal vias just below E-pad | 0 vias ⇒ 9 vias: 26% reduction |
| 7. Number of vias on the periphery of a device vs. thermal resistance | Increasing the number of vias on the periphery of a device | 0 vias \Rightarrow 10 vias: 15% reduction |
| 8. Spacing between the package mold and vias on its periphery vs. thermal resistance | Placing thermal vias close to the package mold on its periphery | 3.0 mm \Rightarrow 0.6 mm: 16% reduction |
| 9. Vias just below E-pad (inner vias) and vias on the periphery of a device (outer vias) vs. thermal resistance | Vias just below E-pad have a greater effect in reducing thermal resistance. | 10 outer vias \Rightarrow 9 inner vias: 9% reduction |
| 10. Device-to-device spacing vs. thermal resistance | Increasing device-to-device spacing reduces thermal interference. | 0.5 mm \Rightarrow 10 mm: 20% reduction |
| 11. Countermeasures for thermal interference vs. thermal resistance | Adding thermal vias between devices | No vias between devices \Rightarrow Adding vias: 10% reduction |
| 12. Effects of a heatsink on thermal resistance | A heatsink helps reduce thermal resistance. The combined use of a heatsink and thermal vias provides a greater effect. | No heatsink \Rightarrow Adding a heatsink: 25% reduction |
| 13. Board orientation vs. thermal resistance | In the case of natural air convection, placing a board in the upright position helps reduce thermal resistance. | Board facing up \Rightarrow Upright landscape orientation: 9% reduction |
| 14. Temperature distribution on the mold surface #1 | (Care should be taken as to the monitor position because the mold surface has a temperature gradient.) | _ |
| 15. Temperature distribution on the mold surface #2 | (Temperature stabilizes when metal tape is affixed on the mold surface.) | _ |
| 16. Air velocity along a model with a heatsink vs. thermal resistance | Thermal resistance decreases greatly when airflow hits a heat sink in the right direction. | No airflow \Rightarrow 1-m/s air velocity: 34% reduction |

Note 1: Cu coverage means the ratio of the area occupied by board traces to the total board area Note 2: E-pad stands for "an exposed pad." It is a metal pad exposed on the bottom of a package. Board thickness: 1.6 mm

Cu coverage: 100% (35 µm thick) on all layers

1. Board size vs. thermal resistance

Question: How much does the board size affect the thermal resistance? Conditions: 1 inch sq. 2 inches sq. 2 inches sq. 3 inches sq. $3 \text$

Conclusion: Increasing the board size, particularly up to two inches square, is beneficial in reducing thermal resistance.

Results: Increasing the board size helps reduce the thermal resistance. This is due to the increased heat dissipation from the board. A board two inches square provides a considerably lower thermal resistance than a board one inch square, but a board three inches square does not produce such a significant effect. (A four-layer board two inches square results lower thermal resistance than a four-layer board one inch square.) Boards up to two inches square provide a significant reduction in thermal resistance.



Note 1: Relative thermal resistance ($R_{th(ch-a)}$) =(each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Relative to a baseline model of a four-layer board two inches square

2. Number of board layers vs. thermal resistance

Question: How much does the number of board layers affect the thermal resistance?



Conclusion: Increasing the number of board layers helps reduce the thermal resistance.

Results: When the board size is equal, increasing the number of board layers helps reduce the thermal resistance. (An eight-layer board results in 14.3% lower thermal resistance than a four-layer board.) This is due to an increase in the heat dissipation to a board because of the increased copper traces. The reductions in thermal resistance level off when the number of layers exceeds 16.



Note 1: Relative thermal resistance ($R_{th(ch-a)}$) = (each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Relative to a baseline model of a four-layer board two inches square

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3. Trace thickness on outer board layers vs. thermal resistance

Question: How much does the trace thickness on the outer layers of a board affect the thermal resistance?

Conditions:

Package: SOP Advance (with a Cu connector) Conditions: $T_a = 25^{\circ}$ C, $P_D = 1.0$ W Board size: 2 inches sq. Number of layers: 2, 4, 8 Board thickness: 1.6 mm Package: SOP Advance Cu coverage: 100% on all layers Trace thickness on the outer layers: 18 to 105 µm Trace thickness on the inner layers: 35 µm



Conclusion: Increasing the trace thickness on the outer layers of a board helps reduce the thermal resistance. This effect diminishes as the number of board layers increases.

Results: Increasing the trace thickness on the outer layers (i.e., top and bottom layers) of a board helps reduce the thermal resistance. (A board with a trace thickness of 105 μ m results in 13% lower thermal resistance than a board with a trace thickness of 35 μ m.) However, boards with a greater number of inner layers provide less reduction in thermal resistance. In the case of a two-layer board, maximizing the trace thickness is beneficial.

Data:



| Trace thickness on | Relative thermal resistance (R _{th(ch-a)}) | | |
|-----------------------|---|------------------|------------------|
| the outer layers | 2-layer board | 4-layer board | 8-layer board |
| 18 µm | 125% | 110% | 98% |
| 35 µm | 105% | 100% | 90% |
| 70 µm | 93% | 91% | 86% |
| 105 µm | 88% | 87% | 86% |

Note 1: Relative thermal resistance ($R_{th(ch-a)}$) = (each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Relative to a baseline model of a board two inches square with a trace thickness of 35 μ m

4. Board Cu coverage vs. thermal resistance #1

Question: How much does the Cu coverage of a board affect the thermal resistance?

Conditions:

Package: SOP Advance (with a Cu connector) Conditions: $T_a = 25$ °C, $P_D = 1.0$ W Cu coverage: 20 to 100% on all layers (See the figures below.) Number of layers: 2, 4, 8 Board size: 2 inches sq. Board thickness: 1.6 mm Trace thickness: 35 μ m on all layers

2 inches 2 inches







Conclusion: Boards with more Cu coverage result in lower thermal resistance.

Results: Boards with more Cu coverage result in lower thermal resistance. (A board with 100% Cu coverage results lower thermal resistance than a board with 20% Cu coverage.) This tendency is not affected by the number of board layers. This is because boards with more Cu coverage have more area to which heat from a device can dissipate.

Data:



| | Relative thermal resistance | | | |
|----------|-----------------------------|------------------|------------------|--|
| Coverage | 2-layer board | 4-layer board | 8-layer board | |
| 100% | 109% | 100% | 83% | |
| 80% | 114% | 104% | 87% | |
| 60% | 124% | 114% | 95% | |
| 40% | 142% | 133% | 122% | |
| 20% | 190% | 182% | 152% | |
| | | | | |

Note 1: Relative thermal resistance ($R_{th(ch-a)}$) = (each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Relative to a baseline model with 100% Cu coverage

5. Board Cu coverage vs. thermal resistance #2

Question: How much do Cu geometries on a board affect the thermal resistance?

Conditions:

Package: SOP Advance (with a Cu connector) Conditions: $T_a = 25^{\circ}$ C, $P_D = 0.5$ W Cu coverage: 11.5 to 100% on all layers (See the right-hand figures.) Number of layers: 4 Board thickness: 1.6 mm Trace thickness on the outer layers: 70 µm Trace thickness on the inner layers: 35 µm





Conclusion: Boards with higher Cu coverage result in lower thermal resistance, irrespective of Cu geometries. Increasing the width of traces near a heat source helps reduce thermal resistance.

Results: As is the case with square Cu coverage, boards with less Cu coverage result in higher thermal resistance regardless of Cu geometries. Even two boards with an equal Cu coverage percentage could result in different thermal resistances, depending on Cu geometries. (The board with wide Cu coverage resulted in 4% lower thermal resistance than the board with narrow Cu coverage.) Cu traces in the vicinity of a heat source are important.



(each_thermal_resistance / baseline_thermal_resistance) × 100 (%)

Note 2: Relative to a baseline model with 100% Cu coverage



Boards with an equal Cu coverage percentage result in different thermal resistances, depending on Cu geometries. The area highlighted by a circle has a significant effect.

oards with higher Cu cove

6. Number of vias just below E-pad vs. thermal resistance

Question: How much do the number and size of vias just below a device affect its thermal resistance?



Conclusion: Increasing the number and size of thermal vias just below E-pad helps reduce the thermal resistance.

Results: Increasing the number of thermal vias just below E-pad helps increase heat dissipation from the backside of a board, reducing the thermal resistance. (A board with nine large vias results in 26% lower thermal resistance than a board with zero vias.) In addition, larger vias are more effective in reducing thermal resistance.

Data:



| Number of vias just | Relative thermal resistance (R _{th(ch-a)}) | | |
|------------------------|--|------------|--|
| E-pad | Small vias | Large vias | |
| 0 | 100% | 100% | |
| 1 | 97% | 93% | |
| 4 | 90% | 82% | |
| 5 | 88% | 80% | |
| 8 | 84% | 75% | |
| 9 | 82% | 74% | |
| 16 | 77% | 69% | |
| 25 | 74% | 67% | |

Note 1: Relative thermal resistance ($R_{th(ch-a)}$) = (each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Small vias: φ 300 µm, 25-µm-thick inner plating Note 3: Large vias: φ 450 µm, 50-µm-thick inner plating

Note 4: Relative to a baseline model with zero vias

7. Number of vias on the periphery of a device vs. thermal resistance

Question: How much do the number and size of vias on the periphery of a device affect its thermal resistance?



Conclusion: Increasing the number and size of thermal vias on the periphery of a device helps reduce its thermal resistance.

Results: Increasing the number of vias on the periphery of a device helps reduce its thermal resistance. (A board with 10 large vias results in 15% lower thermal resistance than a board with zero vias.) As is the case with vias just below E-pad, larger vias are more effective in reducing thermal resistance.

Data:



| Number of vias on the | Relative thermal resistance (R _{th(ch-a)}) | | |
|--------------------------|---|------------|--|
| periphery of a device | Small vias | Large vias | |
| 0 | 100% | 100% | |
| 3 | 96% | 92% | |
| 6 | 93% | 88% | |
| 10 | 90% | 85% | |
| 19 | 87% | 82% | |

Note 1: Relative thermal resistance ($R_{th(ch-a)}$) = (each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Small vias: φ 300 µm, 25-µm-thick inner plating Note 3: Large vias: φ 450 µm, 50-µm-thick inner plating

Note 4: Relative to a baseline model with zero vias

8. Spacing between the package mold and vias on the periphery of a device vs. thermal resistance

Question: How much do vias on the periphery of a device affect its thermal resistance?

Conditions:

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Package: SOP Advance (with a Cu connector) Conditions: $T_a = 25$ °C, $P_D = 1.0$ W Mold-to-via spacing: See the figure below. Number of outer vias: 19 Number of layers: 4 Board size: 2 inches sq. Board thickness: 1.6 mm Cu coverage: 100% (35 µm thick) on all layers





Conclusion: Placing thermal vias close to a device helps reduce its thermal resistance.

Results: Large vias in the vicinity of a device help reduce its thermal resistance. (Large vias placed at a distance of 0.6 mm from a device result in 16% lower resistance than those placed at a distance of 3.0 mm.)



Note 1: Relative thermal resistance ($R_{th(ch-a)}$) = (each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Small vias: φ 300 µm, 25-µm-thick inner plating

Note 3: Large vias: φ 450 µm, 50-µm-thick inner plating

Note 4: Relative to a baseline model with an X distance of 3.0 mm

9. Vias just below E-pad (inner vias) and vias on the periphery of a device (outer vias) vs. thermal resistance

Question: How do vias just below a device and those on its periphery affect its thermal resistance?

Conditions:

Package: SOP Advance (with a Cu connector) Conditions: $T_a = 25^{\circ}$ C, $P_D = 1.0$ W Number of vias: Inner vias: 0 to 25 (See the figures below.) Outer vias: 0 to 19 (See the figures below.) Number of layers: 4 Board size: 2 inches sq.

Board thickness: 1.6 mm Cu coverage: 100% (35 μm thick) on all layers Heatsink (20 mm thick) 1 4 5 0 3



Blue box: Inner vias

Red box:Outer vias

Conclusion: Placing vias just below E-pad is more effective in reducing the thermal resistance.

Results: Placing vias just below E-pad is more effective in reducing the thermal resistance of a device. (Thermal resistance is reduced from 90% to 82% when the vias condition changes from ten outer vias to nine inner vias.) An equal reduction in thermal resistance can be achieved with less than half the number of inner vias.



Note 1: Relative thermal resistance ($R_{th(ch-a)}$) = (each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Small vias: φ 300 μ m, 25- μ m-thick inner plating Note 3: Relative to a baseline model with zero vias

10. Device-to-device spacing vs. thermal resistance

Question: How does device-to-device spacing affect thermal resistance?



Conclusion: Reducing device-to-device spacing increases thermal resistance because of the effect of thermal interference.

Results: When multiple devices arranged in a row dissipate the same amount of power, reducing the device-to-device spacing results in an increase in thermal resistance. (The devices exhibit 20% lower thermal resistance when placed with 10-mm spacing than when placed with 0.5-mm spacing.) A device placed between two other devices exhibits a greater increase in thermal resistance. This is because such a device is affected by thermal interference due to the heat from both sides.

Data:



Note 1: Relative thermal resistance ($R_{th(ch-a)}$) = (each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Relative to a baseline model at the center (PKG3) with 0.5-mm device-to-device spacing

11. Countermeasures for thermal interference vs. thermal resistance

Question: How to reduce thermal interference between devices?

Conditions:

Number of devices: 5 Package: SOP Advance (with a Cu connector) Conditions: $T_a = 25^{\circ}C$, $P_D = 1.0$ W per device Number of layers: 4 Board size: 4 × 2 inches Board thickness: 1.6 mm Cu coverage: 100% (35 µm thick) on all layers Device-to-device spacing: 1 mm Traces between devices are cut. Vias between devices are modeled with solid traces.



Conclusion: Adding vias between devices helps reduce their thermal interference.

Results: The above results compare the effects of two countermeasures for thermal interference. Cutting traces between devices results in a reduction in heat dissipation from the devices. This does not help reduce their thermal interference and leads to an increase in thermal resistance. Care should be exercised in cutting traces between heat-generating devices. In contrast, vias on the periphery of devices help reduce the amount of heat flowing from adjacent devices. These vias help reduce thermal interference between devices and increase heat dissipation to other layer traces. (No vias between devices \Rightarrow Adding vias: 10% reduction)

Data: Examples of countermeasures for thermal interference



thermal resistance R_{th(ch-a)} 90% 80% None — Cutting traces — Adding vias between devices Relative 70% PKG2 PKG4 PKG5 PKG1 PKG3 PKG No

| for thermal | (Kth(ch-a)) | | | | |
|-----------------------------|-------------|------|------|------|------|
| interference | PKG1 | PKG2 | PKG3 | PKG4 | PKG5 |
| None | 92% | 98% | 100% | 98% | 92% |
| Cutting traces | 95% | 101% | 103% | 101% | 95% |
| Adding vias between devices | 83% | 88% | 90% | 88% | 83% |
| | | | | | |

Note 1: Relative thermal resistance ($R_{th(ch-a)}$) = (each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Relative to the device model at the center (PKG3) without any countermeasure

12. Effects of a heatsink on thermal resistance

Question: How effective is a heatsink? What is an effective way of using a heatsink?

Conditions:



Conclusion: A heatsink considerably reduces the thermal resistance. Combining a heatsink with vias helps further reduce thermal interference and therefore thermal resistance.

Results: Thermal resistance can be further reduced by attaching a heatsink on the backside of a board in addition to implementing a countermeasure for thermal interference. A heatsink has a significant effect on the vias that conduct heat to the backside of the board. (No heatsink ⇒ Adding a heatsink: 25% reduction; No heatsink ⇒ Adding a heatsink and vias between devices: 43% reduction)



Note 1: Relative thermal resistance ($R_{th(ch-a)}$) = (each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Relative to the device model at the center (PKG3) without a heatsink and a countermeasure for thermal interference

13. Board orientation vs. thermal resistance

Question: How much does the board orientation affect thermal resistance?



Conclusion: In natural air convection, placing a board in the upright position helps reduce thermal resistance. The landscape orientation is particularly effective.

Results: In natural air convection, devices mounted on the backside of a board (i.e., a board with devices facing down) exhibit the highest thermal resistance. When a board is placed upright in the landscape orientation, the devices exhibit the lowest thermal resistance. (Board placed facing up \Rightarrow Board placed upright in the landscape orientation: 9.4% reduction) The device model at the center (PKG3) has the highest thermal resistance because of the effects of thermal interference.



Note 1: Relative thermal resistance ($R_{th(ch-a)}$) = (each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Relative to the device model at the center (PKG3) on a board placed with its top side facing up

14. Temperature distribution on the mold surface #1

Question: Where is the mold surface temperature measured?

Conditions:

Package: SOP Advance (with a Cu connector) Device with a large chip Device with a small chip Conditions: $T_a = 25^{\circ}$ C, $P_D = 1.0$ W Number of layers: 4 (2 inches sq.) Board thickness: 1.6 mm Cu coverage: 100% (35 µm thick) on all layers



Conclusion: Care should be taken as to the monitor position because the mold surface has a temperature gradient.

Results: There is a difference in temperature at the center and edge of the mold. The temperature distribution images indicate that the center of the mold does not always have the highest temperature. When you use a thermocouple or other temperature probe, you need to exercise care as to which part of the mold becomes hot.

Data:



| Structure | Large chip located on the center of E-pad | Small chip located on the side of E-pad | Temperature monitor point |
|--|---|---|--|
| Temperature distribution on the mold surface | | | из — ста Мад-1-19 Мад-1-19 Мад-1-19 Мад-1-19 Мад-1-19 Мад-1-19 Мад-1-19 Мад-1-19 Мад-1-19 Мад-1-19 |
| Temperature difference on the mold surface | 2.03°C | 2.24°C | - |

15. Temperature distribution on the mold surface #2

Question: How does metal tape affect the temperature distribution on the mold surface?

Conditions:

Package: SOP Advance (with a Cu connector) Device with a large chip Device with a small chip Conditions: $T_a = 25^{\circ}$ C, $P_D = 1.0$ W Number of layers: 4 (2 inches sq.) Board thickness: 1.6 mm Cu coverage: 100% (35 µm thick) on all layers Metal tape: Aluminum (50 µm)



Conclusion: Affixing metal tape on the mold surface makes it possible to take stable temperature measurements.

Results: Affixing metal tape on the top surface of the package mold evens out the temperature distribution under the tape. Note that the metal tape causes the measured temperature to be slightly lower than the chip temperature. The model with a small chip exhibits a temperature that is 1 to 1.5% lower than the chip temperature. However, the benefit of obtaining stable measurements is significant. (In the case of a model with a large chip, the tape surface has a temperature gradient as small as 0.18°C.)



16. Air velocity along a model with a heatsink vs. thermal resistance

Question: How is airflow effective when a heatsink with fins is used?

Conditions:

Package: SOP Advance (with a Cu connector) Conditions: $T_a = 25^{\circ}$ C, $P_D = 2.0$ W Number of layers: 4 (2 inches sq.) Board thickness: 1.6 mm Cu coverage: 100% (35 µm thick) on all layers Air velocity: 0 to 10 m/s (See the table below.)





The arrows indicate the direction of airflow.

Conclusion: Thermal resistance decreases greatly when airflow hits a heatsink in the right direction.

Results: Creating airflow in parallel with the fins of the heatsink causes thermal resistance to decrease until the air velocity reaches roughly 1 m/s. (No air flow \Rightarrow 1-m/s air velocity: 34.2% reduction) When the air velocity exceeds 1 m/s, the thermal resistance curve levels off. When a heatsink with fins is used, airflow helps reduce the thermal resistance considerably.

Data:



| Air velocity (m/s) | Relative thermal resistance R _{th(ch-a)} |
|-----------------------|--|
| 0.0 | 100% |
| 0.2 | 83.0% |
| 0.5 | 70.9% |
| 1.0 | 65.8% |
| 2.0 | 62.5% |
| 3.0 | 61.0% |
| 5.0 | 58.7% |
| 10 | 55.6% |
| 10 | 55.070 |

Note 1: Relative thermal resistance ($R_{th(ch-a)}$) = (each_thermal_resistance / baseline_thermal_resistance) × 100 (%) Note 2: Relative to a model with an air velocity of 0 m/s

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